A new silicon-mediated elimination-rearrangement †

Stefano Menichetti^a and Charles J. M. Stirling^{*,b}

^a Dipartimento Di Chimica Organica, Universita Di Firenze, 50121 Firenze, Via Gino Capponi 9, Italy

^b Department of Chemistry, University of Sheffield, Sheffield S3 7HF, UK

Treatment of trimethylsilylethanes bearing α -phenyl groups and β -phenylthio, phenylsulfonyl or cyano groups with LDA causes elimination-rearrangement mediated by the β -carbanionic species. Mechanistic conclusions are based on isotopic labelling experiments, the effects of substituents and approximate kinetics. These suggest that trimethylsilyl is the migrating group, that cleavage of the bond to the leaving group is little advanced in the transition structure and that placing of a substituent to encourage Si-C bond cleavage is mandatory.

Fleming has likened¹ the silicon atom of a silane to a proton, and against this background we extended our work on eliminations in carbon systems² to eliminations in silanes. We have shown³ that reactions of silanes **1** with simple bases/nucleophiles follow (i) protophilic and (ii) silicophilic pathways (Scheme 1). Pathway (i), analogous to that in carbon



systems, gives the alkene 2 by deprotonation and (probable) concerted loss of a range of leaving groups. The rate of elimination showed a primary kinetic deuterium isotope effect for system 1a greater than unity and this pathway was also followed for 1b. The silicophilic pathway (ii), however, predominated for all leaving groups studied. This pathway was also dominant with the strongly silicophilic but poorly protophilic fluoride ion.⁴

These observations prompted us to examine a very strongly basic and poorly nucleophilic (silicophilic) species, lithium diisopropylamide (LDA). Our objective was to find out whether the silicophilic vs. protophilic balance would alter in systems with LG = SPh, SO_2Ph and CN.

When α -phenylsilanes **1a**- α were treated with a 4 molar excess of LDA in THF (Table 1, entries 1–6) neither pathway (i) or (ii)

was significant; instead the major product in each case was the styryl silane 4. Only in the case of 1a was a minor proportion of the protophilic product 2 formed. These observations reveal a new rearrangement involving [1,2]carbon-to-carbon migration of either a silyl or phenyl group. An anionic carbon-to-carbon silicon migration has been reported previously ⁵ but occurs only in special cases. A number of questions about the mechanism of this process arise and these we address in order. Results are collected in Table 1.

Which is the deprotonation site and is the process concerted or stepwise?

Our working hypothesis was that deprotonation at C_{β} occurs with subsequent intramolecular attack at silicon (structure 5) or at the phenyl group (structure 6). When partly-reacted reaction



mixtures of **1b** and of **1c** were quenched with D_2O the ¹H NMR of the recovered starting materials showed that deprotonation had rapidly occurred at C_{β} only with no incorporation of D elsewhere. In the case of **1a** no incorporation of D was observed and clearly for this substrate, deprotonation is involved in the rate-determining step. For substrates **1b** and **1c** but not **1a**, the approximate half-lives are independent of the [substrate]: [LDA] ratio. The results are consistent with either of processes **5** and **6**; for **1a** deprotonation appears to be concerted with rearrangement.

In reactions with the silyl sulfone **1b**, 10% of styrene accompanied the rearrangement product, **4**, in reactions at 25 °C. Control experiments showed no reaction of PhSO₂Li with the starting material; however, with sodium deuteroxide in D₂O, the reaction occurred smoothly (Scheme 2). The products



are consistent with silicophilic attack of the hydroxy ion on the starting material which becomes partially deuteriated with

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	Entry	Substrate	<i>T/</i> °C	$t_{\frac{1}{2}}/h^{b}$	Ratio 4:2	Conversion ^c	Yield $\binom{0}{0}$ (2 + 4) ^d	
····	1	1a	25		e	0	_	
	2	1a	67	11 ^a ; 5.5 ^f	10:1 ^e	100	80	
	3	1b	25	132	100:0	100	_	
	4	1b	67	$1.5^{g,h,i}$	100:0	100	79	
	5	lc	25	48	100:0	100	_	
	6	1c	67	1.59	100:0	100	63	
	7	le	67	1	_	100	60 ^{<i>j</i>,<i>k</i>}	
	8	15	67	!		_	_	
	9	16	67	l	_		_	
	10	17	25	∞	_	0	_	
	11	17	67	15	4:1	90	65	
	12	17	67	40	Traces ^m			

^{*a*} 4 Equivalents in THF. ^{*b*} Approximate. ^{*c*} By ¹H NMR. ^{*d*} Isolated. ^{*c*} No incorporation of deuterium in part reactions on D₂O quenching. ^{*f*} With 10 equiv. LDA. ^{*g*} With 4 or 10 equiv. of LDA. ^{*h*} If HCl is used in quenching, 10% of styrene is formed from 4b. ^{*i*} The E/Z ratio was 85:15 and independent of [LDA]. ^{*j*} Product is vinyltrimethylsilane. ^{*k*} Trapped as adduct with 4-CH₃C₆H₄SCl; see text. ^{*i*} No reaction detected after 24 h. ^{*m*} Main product is styrene.

concomitant formation of styrene. The alternative of silicophilic attack on the rearrangement product 4 (R = Ph) is not consistent with the labelling pattern.

What is the dependence of the reaction on the leaving group?

For the tentative intermediates/transition structures 5 and 6 two important effects of the leaving group can be envisaged; firstly, deprotonation is much greater with 1b and 1c than with 1a. Matthews et al.⁶ have measured pK_as (in DMSO) for PhSMe, PhSO₂Me and MeCN at ca. 35, 29 and 31 respectively. Dissociation will therefore be complete for 1b and 1c in the presence of LDA. Consistently, as mentioned above, rates for these two substrates are independent of LDA concentration. Secondly, the departure of the leaving group must be involved in the RDS for substrates 1b and 1c as shown by the H/D exchange observations. Earlier work from our group has examined nucleofugalities of SPh, SO₂Ph and CN in βeliminations activated either by carbanion-stabilising groups or by β -silicon.^{2,3} A striking pattern emerges from this earlier work; while SPh and SO₂Ph have rather similar nucleofugalities, that of CN is very low. Cyanide is a rarely encountered leaving group except in carbonyl-forming eliminations.⁷ Notwithstanding this difference, however, the reactivities of 1b and 1c are similar. This implies rather little separation of the leaving group in the transition structure of the elimination-rearrangement. In this connection, we plan to use 'Hammett' leaving groups to test the sensitivity of the system and hence draw further conclusions about the β -C–LG cleavage.

What is the direction of the rearrangement?

We established that it is the silicon atom and not the phenyl group that becomes attached to C_{g} . Substrate 7 with deuterium at C_{α} was prepared by photoaddition of PhSD to α -styryltrimethylsilane, 2 (R = Ph) and subsequent oxidation. Treatment of 7 with LDA under the usual conditions gave a mixture of 8 and 9 while the sulfone 10, obtained by quenching the sulfonyl-stabilised anion 5 with D₂O, gave a mixture of the styrenes 11 and 12 as well as 4 (R = Ph) (Scheme 3). These results exclude migration of the phenyl group; when the label and the phenyl group are on the same atom they are not separated and when they are on adjacent atoms, they are not brought together.

What is the scope of the rearrangement?

The requirement for the α -phenyl group was explored by subjecting the unsubstituted sulfone **1d** to the reaction conditions. The only product was vinyltrimethylsilane **2** (R = H). This product is that to be expected from either α protophilic elimination or β -protophilic rearrangement-elimination. These alternatives were again distinguished by isotopic





labelling. Sulfone 1e (entry 7) was treated with a three-fold excess of LDA in THF and the volatiles were distilled off into a solution of toluene-*p*-sulfenyl chloride at -30 °C. Sulfide 13 but none of the isomer 14 was isolated showing that no rearrangement has occurred (Scheme 4).



Evidently the phenyl group is required for rearrangement. This is notwithstanding the fact that it must considerably accelerate the α -protophilic pathway, as seen for β -elimination

in alkyl halides which a β -phenyl group can accelerate some 500-fold.⁸ In the silicophilic rearrangement, the role of the phenyl group is, presumably, to weaken the Si–C bond, a phenomenon clearly seen in the ejection of carbon leaving groups in nucleophilic attack at silicon.⁹

With regard to the nature of the β -carbanion which initiates the rearrangement, we altered the basicity of this ion in structures 15 and 16 (Scheme 5). These substrates are much



Scheme 5 Reagents: i, PhCH₂SO₂Ph, LDA, THF; ii, PhSO₂CH₂-SO₂Ph, EtONa, EtOH

more acidic than **1b**; **15** can be compared with PhCH₂SO₂-Ph, $pK_a(DMSO) = 23.4^{10}$ and **16** with $(PhSO_2)_2CH_2$, $pK_a(DMSO) = 12.2.^{11}$ Even in forcing conditions (LDA in THF at reflux) neither sulfone reacted by any of the three possible pathways. The substrates would essentially be completely ionised under the reaction conditions, suppressing the protophilic pathway. The silicophilic pathway is not observed with the very weakly silicophilic and hindered amide ion and the stabilised β -carbanion is evidently too unreactive to engage in the rearrangement–elimination sequence.

What is the dependence of the elimination-rearrangement on the separation of silicon and distal carbanion?

We have not made a comprehensive study of this point but we have examined the behaviour of substrate 17 (Scheme 6).



Treatment of 17 with an excess of LDA-THF under the standard conditions slowly gave (Table 1) a 4:1 mixture of the rearrangement product 4 and the protophilic elimination product 2. These observations are consistent with rearrangement only via the β -carbanion (Scheme 6). This is slow, presumably because of the formation of the β , δ -dicarbanion, and allows competition via the protophilic pathway mediated by deprotonation at C_a. When 17 is briefly treated with an excess of LDA and then quenched with D₂O, it is recovered with deuterium at both β and δ positions. When, however, only a slight excess (1.2 equiv.) of LDA is used, quenching with D₂O gives only δ -deuteriated starting materials. When the mixture is kept at elevated temperatures over a long period, the main product is styrene with traces of protophilic product 2 and β -rearrangement product 4. Styrene can result either from

intermolecular or intramolecular silicophilic attack by the δ -carbanion. Clearly there is no favouring of a five (δ) versus three (β) ring transition structure for rearrangement.¹²

Conclusions

This new rearrangement requires a β -leaving group which is also carbanion-stabilising together with an appropriate α substituent, such as phenyl, to weaken the α -carbon-silicon bond selectively. The transition structure appears to involve little carbon-leaving group bond fission and a three-ring transition structure is probably preferred over other ring sizes.

Experimental

¹H and ¹³C NMR spectra were recorded in CDCl₃ at 250 and 75 MHz, using residual CHCl₃ at $\delta_{\rm H}$ 7.27 and the central line of CDCl₃ at $\delta_{\rm C}$ 77.00 as references; *J* values are given in Hz. IR spectra were recorded on a Perkin-Elmer 1725X infrared spectrometer. Melting points were obtained using a Kofler hotstage apparatus and are uncorrected. Tetrahydrofuran (THF) was distilled from sodium benzophenone ketyl. Trimethylsilyl chloride and diisopropylamine were distilled before use. All other commercial reagents were used as received without further purifications. Lithium diisopropylamide (LDA)¹³ and toluene-*p*-sulfenyl chloride¹⁴ were prepared following literature procedures. Light petroleum refers to the fraction bp 40–60 °C.

a-Trimethylsilylstyrene 2

α-Bromostyrene (13.40 g, 74.0 mmol) in dry THF (50 cm³) was added dropwise during 1 h to a suspension of magnesium turnings (1.80 g, 75.0 mmol) in dry THF (50 cm³). Trimethylsilyl chloride (8.60 g, 80.0 mmol) in dry THF (50 cm³) was added and the mixture heated at reflux for 5 h with complete consumption of the magnesium. Quenching with saturated aqueous ammonium chloride and extraction with dichloromethane (3 × 50 cm³) gave crude material which was distilled *in vacuo* to give **2** (10.42 g, 79%) as a colourless oil, bp 90 °C/18 mmHg (lit.,¹⁵ 73–77 °C/8 mmHg); $v_{max}(neat)/cm^{-1}$ 3042, 2945, 1595, 1245; $\delta_{\rm H}$ 7.42–7.33 (m, 5 H), 5.91 (d, J 2.4, 1 H), 5.68 (d, J 2.4, 1 H), 0.28 (s, 9 H).

1-Phenylthio-2-phenyl-2-trimethylsilylethane 1a

A mixture of thiophenol (2.40 g, 2.2 mmol), α -trimethylsilylstyrene **2** and azoisobutyronitrile (AIBN) (50 mg, 0.3 mmol) was heated at 90 °C for 1 h, when additional AIBN (60 mg) was added and the mixture was again heated at 90 °C for 1 h. The crude product was purified by bulb-to-bulb distillation (bp 170 °C/0.5 mmHg) to give **1a** (4.90 g, 86%) as a pale yellow oil; $v_{max}(neat)/cm^{-1}$ 3060 and 3020, 2950, 1600, 1585, 1250; $\delta_{\rm H}$ 7.30–7.02 (m, 10 H), 3.45–3.30 (m, AB part of an ABX system, 1 H), -0.01 (s, 9 H).

By the same procedure the following silyl sulfides were prepared and oxidised (below) to the corresponding sulfones without further purifications: 1-phenylthio-2-trimethylsilyl-ethane from thiophenol and vinyltrimethyl silane; 1-phenylthio-2-trimethylsilyl[2^{-2} H]ethane from PhSD and vinyl-trimethylsilane; 1-phenylthio-2-phenyl-2-trimethylsilyl[2^{-2} H]-ethane from PhSD and **2**; 1-benzylthio-2-phenyl-2-trimethylsilyl[2^{-2} H]-ethane from PhCH₂SD and **2**.

General procedure for the preparation of sulfones 1b, 1d, 1e, 7 and 17

To a solution of the sulfide in methanol, ammonium molybdate heptahydrate $[(NH_4)_6Mo_7O_{24}\cdot7H_2O]$ (0.05 equivalents) and 30% aqueous hydrogen peroxide (6 equivalents) were added and the mixture was kept at 20 °C for 16 h. The mixture was diluted with brine and extracted with dichloromethane. The organic layer was washed successively with aqueous 10%

sodium hydrogen sulfite, and brine and dried (Na_2SO_4) . Evaporation gave the crude sulfone which was purified by chromatography on silica and/or recrystallisation.

1-Phenylsulfonyl-2-phenyl-2-trimethylsilylethane 1b. Mp 109– 111 °C (ethanol) (65%) (Found: C, 63.97; H, 7.05; S, 9.89. $C_{17}H_{22}O_2SSi$ requires C, 64.11; H, 6.96; S, 10.07%); $\nu_{max}(KBr)/cm^{-1}$ 3065 and 3030, 2980 and 2930, 1610 and 1595, 1320, 1260, 1150; $\delta_{\rm H}$ 7.58–7.52 (m, 2 H), 7.44–7.35 (m, 1 H), 7.28–7.19 (m, 2 H), 7.02–6.88 (m, 3 H), 6.76–7.71 (m, 2 H), 3.74 (dd, *J* 12.5 and 14.5, 1 H), 3.37 (dd, *J* 2.0 and 14.5, 1 H), 2.68 (dd, *J* 2.0 and 12.5, 1 H), -0.08 (s, 9 H).

1-Phenylsulfonyl-2-trimethylsilylethane 1d. Mp 49–51 °C (hexane) (81%) (Found: C, 54.79; H, 7.35; S, 13.48. C₁₁H₁₈O₂SSi requires C, 54.5; H, 7.48; S, 13.23%); $\nu_{\text{max}}(\text{KBr})/\text{cm}^{-1}$ 3094 and 3062, 2954 and 2901, 1585; 1309, 1260, 1139; δ_{H} 7.90–7.85 (m, 2 H), 7.70–7.50 (m, 3 H), 3.02–2.92 (m, 2 H), 0.94–0.84 (m, 2 H), 0.94–0.84 (m, 2 H), -0.04 (s, 9 H).

1-Phenylsulfonyl-2-trimethylsilyl[**2-**²**H**]**ethane** 1e. Mp 47– 52 °C (hexane) (80%); ¹H NMR showed 70% deuteriation at position 2: $\delta_{\rm H}$ 7.90–7.85 (m, 2 H), 7.70–7.50 (m, 3 H), 3.02–2.92 (m, 2 H), 0.94–0.84 (m, 0.6 H), -0.04 (s, 9 H).

1-BenzyIsulfonyl-2-phenyl-2-trimethylsilylethane 17. Mp 124.5–126 °C (ethanol) (22.5%); (Found: C, 64.91; H, 7.23; S, 9.48. $C_{18}H_{24}O_2SSi$ requires C, 65.06; H, 7.22; S, 9.63%); $v_{max}(KBr)/cm^{-1}$ 3075 and 3050, 2975 and 2930, 1610, 1310, 1260, 1135; $\delta_{\rm H}$ 7.42–7.01 (m, 10 H), 3.61 (br s, AB system, 2 H), 3.50 (dd, J 11.6 and 14.6, 1 H), 3.10 (dd, J 1.4 and 14.6, 1 H), 2.79 (dd, J 1.40 and 11.60, 1 H), -0.02 (s, 9 H).

1-Phenylsulfonyl-2-phenyl-2-trimethylsilyl[**2-**²**H**]**ethane 7.** Mp 107–111 °C (ethanol) (61%); ¹H NMR showed 60% deuteriation at position 2: $\delta_{\rm H}$ 7.58–7.52 (m, 2 H arom.), 7.44–7.35 (m, 1 H), 7.28–7.19 (m, 2 H), 7.02–6.88 (m, 3 H), 6.76–7.71 (m, 2 H), 3.74 (m, 1 H), 3.37 (m, 1 H), 2.68 (m, 0.4 H), -0.08 (s, 9 H).

1-Cyano-2-phenyl-2-trimethylsilylethane 1c

To a mixture of trimethylsilyl chloride (10.80 g, 100 mmol) and magnesium turnings (800 mg, 33 mmol) in hexamethylphosphorus triamide (HMPT) (30 cm³) kept at 40–50 °C, cinammonitrile (4.30 g, 33 mmol) in HMPT (10 cm³) was added dropwise during 1 h. The mixture was kept at 70 °C for 12 h, diluted with ether and quenched with ice. The organic phase was separated, washed with water until neutral, dried over anhydrous sodium sulfate and evaporated to give the crude product which was purified by bulb-to-bulb distillation (bp 170 °C/0.7 mmHg) to give 1-cyano-2-phenyl-1,2-bis(trimethylsilyl)ethane (6.5 g) $[v_{max}(C=N \text{ str}) 2220 \text{ cm}^{-1}$, lit.,¹⁶ 2215 cm⁻¹] as a glassy solid which was directly used for the preparation of 1c without further purification.

To a solution of 1-cyano-2-phenyl-1,2-bis(trimethylsilyl)ethane (4.0 g, 14.5 mmol) in acetic acid (10 cm³), aluminium trichloride (260 mg, 2 mmol) was added and the mixture was heated at reflux for 24 h. The dark solution was diluted with water (40 cm³) and extracted with dichloromethane (3 × 40 cm³). The organic phase was washed with aqueous saturated sodium hydrogen carbonate and with brine, dried (Na₂SO₄) and evaporated to give crude material which was chromatographed on silica [ethyl acetate–light petroleum (1:20)] to give 1c (2.4 g, 80%), mp 42–43 °C (lit.,¹⁶ 46 °C) from hexane; v_{max} (KBr)/cm⁻¹ 3060 and 3020, 2950 and 2895, 2210, 1600, 1250; $\delta_{\rm H}$ 7.30–7.01 (m, 5 H), 2.75 (m, 2 H), 2.42 (m, 1 H), 0.02 (s, 9 H).

1-Phenyl-1-phenylsulfonyl-2-trimethylsilylethane 15

To lithium diisopropylamide (4 mmol) in dry THF (10 cm^3), benzyl phenyl sulfone (928 mg, 4 mmol) in THF (20 cm^3) was added and the mixture kept at 0 °C for l h. Bromomethyltrimethylsilane (835 mg, 5 mmol) in THF (3 cm^3) was added and the mixture was heated at reflux for 15 h. Quenching with saturated aqueous ammonium chloride and dichloromethane extraction $(3 \times 30 \text{ cm}^3)$ gave crude material which was recrystallised to give **15** (840 mg, 66%) as pale yellow crystals, mp 78.5–79.5 °C (from hexane) (Found: C, 64.22; H, 7.07; S, 9.89. C₁₇H₂₂O₂SSi requires C, 64.1; H, 6.91; S, 10.06%); $\nu_{\text{max}}(\text{KBr})/\text{cm}^{-1}$ 3090, 3067 and 3030, 2958 and 2905, 1606, 1308, 1249, 1145, δ_{H} 7.55–7.02 (m, 10), 4.05 (m, 1 H), 1.65 (m, J_{AB} 12.5, 2 H), 0.02 (s, 9 H).

1,1-Bis(phenylsulfonyl)-2-trimethylsilylethane 16

To bis(phenylsulfonyl)methane (889 mg, mmol) in anhydrous ethanol (50 cm³), sodium (70 mg, 3 mmol) was added. A white solid precipitated from the solution and after 1 h at 20 °C bromomethyltrimethylsilane (730 mg, 4.1 mmol) was added and the mixture was heated at reflux for 23 h. TLC showed the presence of starting material and additional bromoethyltrimethvlsilane (501 mg, 3 mmol) was added. The mixture was refluxed for 70 h, quenched with saturated ammonium chloride and extracted with dichloromethane to give a crude product which was chromatographed on silica [ethyl acetate-light petroleum (1:3)] to give 16 (286 mg, 25%), mp 99-101 °C (from ethanol) (Found: C, 53.25; H, 5.89; S, 17.01. C₁₇H₂₂O₄S₂Si requires C, 53.37; H, 5.80; S, 16.76%); v_{max}(KBr)/cm⁻¹ 3110, 3090 and 3060, 2950 and 2930, 1585, 1330, 1250, 1155; $\delta_{\rm H}$ 7.95–7.90 (m, 4 H), 7.73-7.65 (m, 3 H), 7.61-7.52 (m, 4 H), 4.48 (t, J 7.0, 1 H), 1.39 (d, J 7.0, 2 H), 0.11 (s, 9 H).

Reaction of substrates 1a-e, 7 and 15-17 with LDA

To a solution of LDA, prepared as described by Brandsma,¹³ the substrate in dry THF was added to give a 0.25-0.30 M solution. The mixture was heated at reflux and monitored by TLC and/or gas chromatography; ¹H NMR integral ratios of small aliquots of the mixture were used for the quantitative measurements of the progress of the reaction. When consumption of the substrate was complete the reaction mixture was quenched with ice and extracted with dichloromethane. Trimethylsilylstyrenes **4** (and/or **2**) were isolated by column chromatography on silica with light petroleum as eluent.

The stabilities of the products to the reaction conditions were confirmed by treating styrenes 2 and 4 with LDA in THF under the reaction conditions, and with water under the working up conditions. Use of 2% HCl in quenching produced *ca.* 10% of styrene from 4b (¹H NMR).

Labelling studies of the direction of the rearrangement

Silyl sulfone **1b** (1.1 g, 3.46 mmol) in THF (15 cm³) at $-60 \,^{\circ}$ C under argon was treated with butyllithium in hexane (3.6 mmol). After 3 h at $-60 \,^{\circ}$ C and 16 h at 15 $^{\circ}$ C, D₂O (10 mmol) was added and after quenching (NH₄Cl-H₂O), extraction and recrystallisation (ethanol) gave the β -monodeuterio compound **10** (57%) which was 100% monodeuteriated α to the phenyl-sulfonyl group as a 44:56 mixture of diastereoisomers.

Treatment of the diastereoisomeric mixture, 10, with LDA in THF at reflux for 4 h gave a mixture of the isomers 11 and 12 (82%) in an 87:13 ratio in which, by ¹H NMR, 64% of the original deuterium had been retained corresponding to a primary deuterium isotope effect of *ca.* 2.

When the α -deuterio substrate 7 was similarly treated, the isomers 8 and 9 (80%) in a 14:86 ratio were obtained. Compound 7 was 60% α -deuteriated and the silyl styrenes obtained also contained 60% of deuterium α - to the phenyl group.

In neither of the pair of experiments was there any evidence for phenyl migration.

Isotope labelling study of elimination vs. rearrangement

Silyl sulfone 1e (729 mg, 3 mmol) in THF (5 cm³) was treated with LDA (12 mmol) in THF (25 cm³). The mixture was kept for 3 h at 67 °C when TLC showed the reaction to be complete. The mixture was quenched with water and extracted (CH₂Cl₂). Distillation of the extracts gave a fraction with bp 36–67 °C which was cooled to -30 °C and treated with toluene-*p*sulfenyl chloride (474 mg, 3 mmol). The colourless solution was kept for 1 h at -30 °C and was then washed with saturated aqueous NaHCO₃ and evaporated to give an oil. This crude product was chromatographed on silica [ethyl acetate–light petroleum (1:20)] to give silane **13** (412 mg, 60%) contaminated with a trace of di-*p*-tolyl disulfide; $\delta_{\rm H}$ 7.45–7.30 (m, 2 H), 7.20–7.10 (m, 3 H), 3.75 (m, 2 H), 2.70 (m, 0.3 H), 2.32 (s, 3 H), 0.24 (s, 9 H), consistent with literature data.¹⁴ The starting sulfone was 70% deuteriated (¹H NMR) at C_a and the label was retained completely at C_a in the trapping product.

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